

mandatory to ensure high ionization rates and safe operations. Several techniques have been investigated in the last decade in order to increase the electron density: Addition of auxiliary electrons can be done by means of active or passive methods (like alumina tubes and other techniques).



i.e. quantum tunneling, which is obtained by

applying an electric field higher than 3-4 V/µm.



Trend of the Kr11+ current (in mA) during the switching on-off of CNTs emission, in a time window of 30 seconds. The CNTs applied voltage was 2500 V, at 35 W RF power.

Current improvements obtained with the 2500 2140 15.4 CNTs-based electron gun can be compared with those observed when using the biasdisk alone. To the latter we applied potentials ranging from 35 to 720 V, but at bias voltages larger than 350 V the extracted current drastically decreases. Conversely, the current is boosted by CNTs for voltages higher than 750 V and then it<br>increases monotonically, slowly monotonically, approaching to saturation above 1000 V.



Changes in the CSD when three different biasing voltages are applied on the CNT extraction grid, at 30 W of RF power. This low power level limits the most evident increase of the extracted current to the lower charge states.

It is also interesting to note the afterglow-like peak when the electron gun is going to switch off. The gain of current is almost 60 % and reaches 100 % during the afterglow peak, at an RF power of 35 W.



Increasing the power, the number of warm electrons increases as well, so that the CSD shifts to higher charge states (because of the larger warm component temperature). However, it can be observed in the Xray spectra that the hot electrons are still damped by the auxiliary electrons.

Current [µA]

 $\overline{\mathbf{z}}$ Current [µ

**EFFECTS OF CNT BASED E-GUN ON CSD INVESTIGATIONS ABOUT THE DAMPING OF THE HOT ELECTRONS**

10 µm 150 µm 300 µm

**X-ray detector**

150 μm thick MICA spacer<br>with central hole (∅ 4 mm)

**Copper GRID** 

MICA SPACER CNT CATHODE

Cu grid  $(80%$  transparence

sylicon chip (12x 12 mm; 280 µm thick) porous alumina layer (2-3 µm ) with catalyst electrodeposited in the pores

w to integrate

bottom

CNTs provide additional and even more important benefits to ECR plasmas: the total suppression of the hot electrons component is evident above 1000 V. The same effect is not evident when using a conventional biased disk, which in addition deteriorates the performances above 350 V. This result is even more important than benefits provided to CSD, because the usage of CNTs-based electron guns may be an effective and reliable technique to further improve the modern ECRIS performances without the strong limitation coming from hot electrons generated at large power and high frequencies.



**Long time operation and CNT electron gun reliability**

**Extracted current of Kr11+ [**µ**A]**

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of Kr<sup>1</sup>

The last part of the experiment was devoted to the verification of<br>the CNT based electron gun CNT based electron gun  $\vec{\mathbf{z}}$ reliability over long time operations. At the given pressure and power the Kr11+ current extracted when the electron gun was on was 40% larger than the current coming out in usual operations. A slowly decaying trend was however evident during the first 8 hours, featuring a weak degradation of the nanotubes. The interruption of output current occurred after 24 hours of cw operations, due to a blackout of the laboratory electrical network.

